





A convenient preparation of pentafluorophenyl fluoro silanes: reactivity of pentafluorophenyl fluorosilane

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Abstract

Pentafluorophenyl(fluoro)silanes $(C_6F_5)_n SiF_{4-n}$ (n = 1, 2) were prepared from the corresponding ethoxysilanes by sequential chlorodeethoxylation with $SOCl_2$ and fluoridation of chlorosilanes with SbF_3 . The conversion of $C_6F_5Si(OEt)_3$ and $C_6F_5SiCl_3$ into $C_6F_5SiF_3$ with anhydrous HF was described. Some reactions of $C_6F_5SiF_3$ with electrophiles and nucleophiles were studied.

Keywords: Pentafluorophenylhalogenosilanes; C-Si bond cleavage; Nucleophilic arylation of electrophiles

1. Introduction

Pentafluorophenyltrialkylsilanes and tetrakis(pentafluorophenyl)silane are easily prepared by different methods [1] and their reactions with halogen fluorides [2,3], xenon difluoride [4], nucleophiles [5] and fluoride-catalysed reactions with electrophiles [6] have been described. Little is known about the reactivity of pentafluorophenylhalogenosilanes $(C_6F_5)_n SiX_{4-n}$ (X = F, Cl, Br; n = 1-3). One reason for this is the absence of convenient or reliable preparative methods. While PhSiCl₃ and Ph₂SiCl₂ were obtained by phenylation of SiCl₄ with PhMgBr or PhLi [7], the reaction of SiCl₄ with C_6F_5MgBr or C_6F_5Li led mainly to $(C_6F_5)_4Si$ [8]. Similar results were obtained by pentafluorophenylation of SiF₄ [9] and SiBr₄ [10]. In situ generated C₆F₅MgBr reacted with SiCl₄ (in excess) to yield a mixture of $(C_6F_5)_n SiCl_{4-n}$ (n = 1-4) [11]. The first successful preparation of C₆F₅SiF₃ was achieved by insertion of SiF₂ into the C-F bond of hexafluorobenzene [12]. C₆F₅SiFCl₂ and C₆F₅SiCl₃ were produced by UVirradiation of C₆F₆ and SiHCl₃ [13] or gamma-irradiation of SiHCl₃ and C₆F₅Cl [14,15], however, all the methods mentioned above have no preparative use. A more convenient synthesis of $(C_6F_5)_n \operatorname{SiBr}_{4-n}$ (n=1-3) was offered by Weidenbruch [9,16] who passed bromopentafluorobenzene over a Si-Cu mixture at 600 °C and isolated $C_6F_5\operatorname{SiBr}_3$, $(C_6F_5)_2\operatorname{SiBr}_2$ and $(C_6F_5)_3\operatorname{SiBr}_3$ after rectification of the reaction mixture in 8%, 9% and 1% yields respectively. Reaction of the bromosilanes with SbF₃ or Na₂SiF₆ gave the corresponding fluorosilanes $(C_6F_5)_n\operatorname{SiF}_{4-n}$ (n=1-3) [10].

We report here new and convenient synthetic procedures for the preparation of pentafluorophenylchloroand fluorosilanes $(C_6F_5)_n SiX_{4-n}$ (X = Cl, F; n = 1, 2) and some reactions of $C_6F_5SiF_3$ with electrophilic and nucleophilic reagents.

2. Results and discussion

2.1. Synthesis of
$$(C_6F_5)_n SiX_{4-n}$$
 $(X = Cl, F; n = 1, 2)$

In 1968 Whittingham [11] published the preparation of pentafluorophenyl(ethoxy)silanes $(C_6F_5)_n Si(OEt)_{4-n}$ from C_6F_5Br , Mg and $Si(OEt)_4$. This method may be scaled-up to 0.4 mol of bromopentafluorobenzene and pentafluorophenyltriethoxysilane (1) (55% yield), bis(pentafluorophenyl)diethoxysilane (3) (35% yield) and tris(pentafluorophenyl)ethoxysilane (trace) were isolated.

Several methods for the conversion of the Si-OEt into the Si-F bond were reported [7,17], but the most

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popular of them were unsuitable for the fluoridation of $C_6F_5Si(OEt)_3$. Heating of silane 1 with K[HF₂] or treatment with anhydrous HF (AHF) at room temperature gave C₆F₅H. Pentafluorophenyltrifluorosilane was obtained from $C_6F_5Si(OEt)_3$ and AHF at -50 °C, but its yield was only 30% and the major product was pentafluorobenzene. Independent experiments have shown that the co-product ethanol reacts with $C_6F_5Si(OEt)_3$ in AHF to give C_6F_5H . C_6F_5H is also formed from C₆F₅SiF₃ and EtOH in AHF, but this reaction proceeds more slowly. To avoid the consumption of C₆F₅Si(OEt)₃ and C₆F₅SiF₃ by ethanol, the fluoridation of C₆F₅Si(OEt)₃ with HF was carried out in the two-phase system AHF- CH_2Cl_2 at -50 °C. This modification gave trifluorosilane 5 in high yield and only a small admixture of pentafluorobenzene.

$$C_6F_5Si(OEt)_3 + HF$$

$$\begin{array}{c}
1 \\
\xrightarrow{\text{CH}_2\text{CI}_2} \\
\xrightarrow{-50^{\circ}\text{C}}
\end{array}
C_6F_5\text{Si}F_3 + \text{EtOH} + C_6F_5H + \text{FSi}(\text{OEt})_3$$
5

Other attempts to fluoridate triethoxysilane 1 were ineffective. Only a trace of $C_6F_5SiF(OEt)_2$ was obtained by bubbling SF_4 into a CH_2Cl_2 solution of silane 1 at room temperature. From the reaction of $C_6F_5Si(OEt)_3$ with $BF_3 \cdot OEt_2$ or BF_3 gas pentafluorophenyltrifluorosilane 5 was obtained only in complex mixtures together with partially substituted silanes $C_6F_5SiF(OEt)_2$, $C_6F_5SiF_2OEt$ and fluoroethoxyboranes.

$$C_6F_5Si(OEt)_3 + BF_3 \cdot OEt_2(or BF_3)$$

$$\frac{1}{\longrightarrow} C_6 F_5 SiF_3 + C_6 F_5 SiF_n (OEt)_{3-n} + (EtOBF_2)_3$$

$$5$$

$$+ (EtO)_2 BF \qquad (2)$$

n = 1,2

The fluoridation of $C_6F_5Si(OEt)_3$ with SbF_3 as well as with ZnF_2 gave $C_6F_5SiF_3$ (major), $C_6F_5SiF_n(OEt)_{3-n}$ (admixtures) and unrecognised fluoro-containing materials [18].

Chlorodeethoxylation of $C_6F_5Si(OEt)_3$ or $(C_6F_5)_2Si(OEt)_2$ with acetylchloride (20 °C, 48 h) was reported [11], but we were unable to reproduce these preparations. Only traces of the desired product were formed when silane 1 and CH_3COCl were stirred continuously at room temperature (96 h) or under reflux (44 h). Also the reaction of $C_6F_5Si(OEt)_3$ with AcCl in the presence of HOAc (40 °C, 48 h) led only to traces of $C_6F_5SiCl_n(OEt)_{3-n}$, whereas a mixture of $C_6F_5SiCl_3$, $C_6F_5SiCl_2OEt$ and, probably, $C_6F_5SiCl_n(OAc)_{3-n}$ was

obtained in the presence of FeCl₃ or ZnCl₂. That failure was unexpected taking into account the successful replacement of OEt groups for chlorine in $C_6F_5SiMe(OEt)_2$ and $C_6F_5Si(CH=CH_2)(OEt)_2$ under the action of AcCl and FeCl₃ [19] and the conversion of C₆F₅SiBu₂OEt into C₆F₅SiBu₂Cl with AcCl and ZnCl₂ (see Experimental section). Therefore we used thionylchloride in the presence of pyridinium hydrochloride (catalyst) as a more powerful reagent. The latter system was used earlier for the effective stepwise substitution of alkoxy groups by chlorine in Si(OR)_{4-n} [20]. Indeed, reflux of pentafluorophenyltriethoxysilane with SOCl₂ and Py · HCl for 24 h resulted in the formation of pentafluorophenyltrichlorosilane (2) in high yield. The intermediate silane C₆F₅SiCl₂OEt could be isolated when the reactants had been refluxed for 4 h only. A similar procedure was employed for the preparation of $(C_6F_5)_2SiCl_2$ (4) from diethoxysilane $(C_6F_5)_2Si(OEt)_2$ (3).

$$(C_6F_5)_nSi(OEt)_{4-n} + SOCl_2$$

$$\xrightarrow{[Py \cdot HCl]} (C_6F_5)_nSiCl_{4-n}$$

$$(n = 1,2)$$
(3)

It is interesting that no reaction was observed between C₆F₅Si(OEt)₃, SOBr₂ and Py when heated at 50 °C for 77 h

Treatment of silanes 2 and 4 with SbF₃ gave fluorosilanes 5 and 6 respectively. Niobium pentafluoride is also available for fluoridation [5]. With the two-phase system AHF-CH₂Cl₂ at -50 °C 2 could be converted also into 5.

$$C_{6}F_{5}SiCl_{3} + SbF_{3} \longrightarrow C_{6}F_{5}SiF_{3} + SbCl_{3}$$

$$2$$

$$5$$

$$3(C_{6}F_{5})_{2}SiCl_{2} + 2SbF_{3}$$

$$(4)$$

$$\frac{4}{\longrightarrow} 3(C_6F_5)_2 SiF_2 + 2 SbCl_3$$

$$6$$
(5)

2.2. Reactivity of pentafluorophenyltrifluorosilane 5

Recently $C_6F_5SiF_3$ and related silanes were successfully used for the substitution of one fluorine atom for a C_6F_5 group in IF_5 [2], BrF_3 [21] and BrF_5 [3,22] in basic media. On the other hand no $[C_6F_5Xe]^+$ cation was formed in the reaction of $C_6F_5SiF_3$ with XeF_2 in CH_2Cl_2 nor in the presence of $BF_3 \cdot OEt_2$. Only ring fluorination without carbon–silicon bond cleavage took place when $[XeF]^+$ $[NbF_6]^-$ was reacted with silane 5 in SO_2FCl [5]. Mechanistic details of these reactions are not known. This circumstance has prompted us to inves-

tigate interactions of pentafluorophenyltrifluorosilane (5) with simple electrophiles and nucleophiles.

The ¹⁹F NMR in either case spectra of C₆F₅SiF₃ solutions in trifluoroacetic or fluorosulfonic acid exhibit the resonance of fluorine atoms bonded to silicon as triplet [⁴J(F-F)]. In AHF trifluorosilane 5 is less soluble and this solution displays a very broad ¹⁹F NMR signal for the SiF₃ group. No changes took place in these acidic solutions during a few days at room temperature.

Pentafluorophenyltrifluorosilane (5) did not react with bromine in MeCN at room temperature. Aryl-silicon bond cleavage proceeded very slowly in excess of liquid bromine (room temperature, 10 days) to give a mixture of trifluorosilane 5, bromopentafluorobenzene and, presumably, $C_6F_5SiF_2Br$ (1:1:0.6 mol). The latter compound was not isolated and only assumed by its ¹⁹F NMR spectrum: -126.90 (F-2, 6), -143.63 (F-4), -159.00 (F-3, 5) and -131.00 (SiF₂Br) [t, ⁴J(F-F) =

11 Hz] ppm. Bromodesilylation was accelerated by AlBr₃. According to the ¹⁹F NMR data, the ratio of $C_6F_5SiF_3$ to C_6F_5Br was 1:4 after 48 h and the total conversion of trifluorosilane 5 into bromopentafluorobenzene was completed after 76 h at room temperature. Co-products were mixed bromofluorosilanes SiF_nBr_{4-n} (n = 1, 2) which were identified by their ¹⁹F NMR spectra. In the presence of AlBr₃ exchange of silicon-bonded fluorine for bromine in trifluorosilane 5 was not observed.

$$C_6F_5SiF_3 + Br_2 + AlBr_3$$

$$\longrightarrow C_6F_5Br + SiF_2Br_2 + SiFBr_3 + AlF_3$$
 (6)

Trifluorosilane 5 and nitronium tetrafluoroborate did not react in dichloromethane as well as in HSO₃F.

$$C_6F_5SiF_3 + [NO_2]^+[BF_4]^- \xrightarrow{HSO_3F \text{ or } CH_2Cl_2} \text{no reaction}$$
(7)

Table 1 The 19 F NMR spectra of pentafluorophenylsilanes C_6F_5SiXYZ (CDCl₃, 35 °C)

X	Y	Z	$\delta(^{19}F)/ppm$	J(19 F-19 F)/Hz			
			$\overline{F-2,6}$	F - 4	F - 3,5	F-Si	
F	F	F	-125.14	-142.93	- 158.97	-134.32 a	(2,4) 6.5; (3,4) 19.1;
							(F-Si-C-C-F) 10.2
F	F	F ^b	125.64	-144.14	-160.08	c	(2,4) 6.5; (3,4) -18.1;
	_	_ 4					(F-Si-C-C-F) 11.6 ¹
F	F	F ^d	- 124.82	-143.03	-159.04	- 134.19 a	(2,4) 6.5; (3,4) 18.5;
	_	_					(F-Si-C-C-F) 10.9
F	F	F e	- 125.93	-143.84	-159.52	−132.76 ^f	(2,4) 6.2; (3,4) 19.7
F	F	OEt d	- 126.0	- 144.3	- 159.4	-130.1	
F	F	OEt g	126.2	-146.5	-160.3	-132.9	
F	OEt	OEt d	- 126.0	-147.0	-160.8	- 132.6	
F	OEt	OEt g	- 126.2	- 149.1	- 161.1	-132.2	
OEt	OEt	OEt :	- 127.00	- 151.38	-162.17		(2,4) 3.5; (3.4) 19.3
F	F :	NR ₂ i	-126.2	-148.2	- 160.9	-135.7	
F	NR_2^{i}	NR ₂ i Cl ^d	- 126.9	-151.2	-162.0	-137.1	
Cl	Cl		- 125.59	- 145.09	- 159.90		(2,4) 6.8; (3.4) 19.4
Cl	Cl	OEt	-126.40	-147.14	-160.75		(2.4) 5.8; (3.4) 19.6
C_6F_5	F	Fв	~127.19	-144.39	-159.33	С	(2.4) 6.0; (3.4) -18.5;
							(F-Si-C-C-F) 12.0
C_6F_5	F	F d	- 126.81	-143.91	-159.37	-129.81	(2,4) 6.0; (3,4) 19.2;
							(F-Si-C-C-F) 12.0
C_6F_5	C_6F_5	F ^d	- 127.53	144.91	-159.70	-158.13	(2,4) 5.6; (3,4) 19.8;
							(F-Si-C-C-F) 11.3
C_6F_5	C_6F_5	F ^b	-127.66	-144.74	-159.22	c	
C_6F_5	Cl	Cl d	-126.34	- 145.51	-159.98		(2,4) 6.3; (3,4) 19.4
C_6F_5	Cl	OEt d	-127.4	-147.6	-160.9		(3,4) 18.8
C ₆ F ₅ C ₆ F ₅	OEt	OEt d	-128.07	-149.48	- 161.57		(3,4) 18.8
C_6F_5	C_6F_5	Cl ^b	-127.06	-145.33	-157.50		(2,4) 5.8; $(3,4)$ – 19.8
C_6F_5	C_6F_5	$C_6F_5^d$	- 127.15	-146.68	-160.16		(2,4) 5.2; (3,4) 19.9
C_6F_5	C_6F_5	$C_6F_5^{b}$	-127.50	-146.21	- 159.66		
Bu	Bu	Bu	-127.44	-153.11	-162.35		(2,4) 3.7; (3,4) 18.0
Bu	Bu	F	-128.44	-150.52	-161.45	-168.32 h	(2,4) 3.8; (3,4) 19.4
Bu	Bu	OEt	-128.18	- 152.24	-162.13		(2,4) 3.7; (3,4) 20.0
Bu	Bu	Bu ^k	- 129.47		- 145.88		(=, , , = , , , , , , , , , , , , , , ,

^{a 1} J(¹⁹ F-²⁹Si) 248 Hz; ^b in CCl₄ [27]; ^c no data; ^d in CH₂Cl₂-CD₂Cl₂; ^e in CD₃CN-EtCN; ^f sharp singlet; ^g neat liquid; ^{h 1} J(¹⁹ F-²⁹Si) 296 Hz; ⁱ NR₂ means piperidino group, solution in hexane; ^k 4 - BuC₆F₄; ¹ see [28].

Previously no reaction of trifluorosilane 5 with IF₅ (acidic media) as well as in chlorofluorocarbons (neutral media) was found [2]. In this paper the inertness of trifluorosilane 5 toward IF₅ in CH_2Cl_2 or AHF is shown. On the other hand, the interaction of compound 5 with $[IF_4]^+$ $[SbF_6]^-$ in HSO_3F led to evolution of SiF_4 (identified by its ^{19}F NMR spectrum and as adduct $SiF_4 \cdot 2$ Py) and formation of the bis(pentafluorophenyl)iodonium cation (identified by IR and ^{19}F NMR spectrum).

$$C_{6}F_{5}SiF_{3} + IF_{5} \xrightarrow{CH_{2}Cl_{2} \text{ or AHF}} \text{ no reaction}$$

$$C_{6}F_{5}SiF_{3} + \left[IF_{4}\right]^{+} \left[SbF_{6}\right]^{-} \xrightarrow[1)HSO_{3}F} \left[\left(C_{6}F_{5}\right)_{2}I\right]^{+}$$

$$(9)$$

The introduction of the second aryl group and the reduction of I(V) to I(III) are subjects for future investigations. The salt $[IF_4]^+$ $[SbF_6]^-$ was dissolved in HSO_3F at room temperature and this solution was characterized by a sharp singlet resonance at 19.5 ppm ($[IF_4]^+$ cation), a broad signal at ca. -110 ppm ($[SbF_6]^-$ anion) of correct relative intensity besides the singlet of HSO_3F (^{19}F NMR) [23]. During the conversion of trifluorosilane 5 into the bis(pentafluorophenyl)iodonium cation $C_6F_5IF_4$ could not be detected. Furthermore, $C_6F_5IF_4$

did not give the $[(C_6F_5)_2I]^+$ cation under the action of HSO_3F or $[IF_4]^+$ $[SbF_6]^-$ in HSO_3F under the same conditions.

Similar to the reactivity of pentafluorophenylhalogenosilanes with electrophiles only a few examples of reactivity with nucleophiles were known from the literature. From pentafluorophenyltrifluorosilane (5) only its hydrolysis to polymeric material [C₆F₅SiO_{1.5}]_n was reported [12]. The same product was obtained from C₆F₅SiFCl₇ [13]. The exhaustive replacement of chlorine by ethoxy groups in C₆F₅SiCl₃ or (C₆F₅)₂SiCl₂ using anhydrous EtOH and Py in ether was described by Whittingham [11]. Weidenbruch converted bromosilanes $C_6F_5SiBr_3$ and $(C_6F_5)_2SiBr_2$ into $C_6F_5SiR_3$ or $(C_6F_5)_2$ SiR, using Grignard reagents RMgBr(I) (R = Me, Et) [9,16]. It was known that the reaction products of C₆F₅SiMe₃ with nucleophiles depends on "hardness" of nucleophile: "hard" [PrO]⁻ pentafluorobenzene and "soft" BuLi led to formation of 4-BuC₆F₄SiMe₃ [5]. The "borderline" nucleophiles (piperidine, lithium piperidide and lithium propanethiolate) reacted at both electrophilic centres of C₆F₅SiMe₃ (silicon and carbon C-4) [5]. Taking into account the high bond energy of silicon-fluorine and the strong electron pair acceptor character of the SiF3 group, the favoured attack of nucleophiles at C₆F₅SiF₃ was not obvious.

Table 2
The ¹³C NMR spectra of pentafluorophenylsilanes C₆F₅SiXYZ (CD₂Cl₂, 35 °C)

X	Y	Z	$\delta(^{13}C)/ppm$				$J(^{13}C-^{19}F)/Hz$
			C-1	C-2,6	C-3,5	C-4	
F	F	F	96.13	151.24	139.07	146.90	(1,2) 27.0; (2,2) 253.1; (2,4) 5.7;
							(3,3) 257.6; (3,4) 13.2; (4,4) 261.9
Cl	Cl	Cl a	106.27	150.41	139.37	146.48	(1,2) 21.8; (2,2) 252.1; (2,4) 5.8;
							(3,3) 256.5; (3,4) 13.2; (4,4) 261.1
Cl	Cl	Cl b,g	105.07	148.88	137.83	144.92	
Cl	C1	OEt b,c	105.61	149.80	138.39	145.03	(1,2) 25.8; (1,4) 2.8; (2,2) 251.3; (2,4)
							5.4; (3,3) 256.2; (3,4) 13.2; (4,4) 259.7
OEt	OEt	OEt b,d	105.92	150.39	138.25	143.69	(1,2) 31.1; (1,3) 3,3; (1,4) 3.3; (2,2)
							246.3; (2,4) 5.7; (3,3) 244.8; (3,4)
	_						13.4; (4.4) 255.4
C_6F_5	F	F	100.73	150.20	138.23	145.78	(1,2) 26.5; (2,2) 248.5; (2,4) 5,7; (3,3)
	_						256.8; (3,4) 13.3; (4,4) 261.1
C_6F_5	Cl	C1	105.86	149.83	138.58	145.51	(1,2) 24.4; (2,2) 250.8; (2,4) 5.8; (3,3)
	_						258.9; (3,4) 13.3; (4,4) 260.9
C_6F_5	C_6F_5	Cl ^a	106.27	150.47	139.37	146.48	(1,2) 21.8; (2,2) 252.1; (2,4) 5.8; (3,3)
_							256.5; (3,4) 13.2; (4,4) 261.1
C_6F_5	C_6F_5	C_6F_5	103.5	150.0	138.0	145.0	(2,2) 248.6; (3,3) 257.5; (4,4) 257.5
Bu	Bu	OEt b,e	108.82	149.50	137.46	142.38	(1,2) 35.2; (2,2) 242.7; (3,3) 253.3;
							(4,4) 254.9
Bu	Bu	F b,f	106.98	149.09	137.56	143.09	(1,2) 29.0; (2,2) 244.1; (2,4) 5.9; (3,3)
							252.6; (3,4) 13.4; (4,4) 256.6

^a in CD₃CN; ^b in CDCl₃; ^c 62.38 (OCH₂), 17.69 (CH₃) ppm; ¹J(OC-H) 141.7 Hz, ¹J(C-H) 122.1 Hz; ^d 59.97 (OCH₂), 18.34 (CH₃) ppm; ¹J(OC-H) 143.7 Hz, ¹J(C-H) 135.1 Hz; ^e 59.61 (OCH₂), 26.48 (CH₃), 25.02 (CH₂), 18.27 (CH₃CH₂O), 14.65, 13.72 (CH₂CH₂Si) ppm; ^f 26.20 (CH₃), 24.43 (CH₂), 15.19 (CH₂), 13.67 (CH₂) ppm, ²J(C-Si-F) 15.5 Hz; ⁸ ¹³C(¹⁹F) decoupled spectrum.

For detection of intermediates at the interaction of trifluorosilane 5 with nucleophiles, all reactions were checked by ¹⁹F NMR spectrometry (Tables 1-3). Addition of 0.34 equivalents EtONa ("hard" nucleophile) to the solution of trifluorosilane 5 in diglyme gave pentafluorobenzene and, probably, a mixture of $C_6F_5SiF_3$, $C_6F_5SiF_2OEt$ and $[C_6F_5SiF_3(OEt)]^-$, which underwent fast Si-F exchange. This assumption arises from comparison of the 19 F NMR spectra of the neutral silanes $C_6F_5SiF_n(OEt)_{3-n}$ (n = 1-3) where F-Si signals were located at -130 to -134 ppm and the spectrum of $[Me_4N]^+$ $[C_6F_5SiF_4]^ \{-104.2 ([SiF_4]^-), -129.2\}$ (F-2, 6), -159.9 (F-4), -164.2 (F-3, 5) ppm (in diglyme) [25]) with the observed resonances at -123.2(Si-F, broad), -126.6 (F-2, 6), -147.6 (F-4) and -160.7 (F-3, 5) ppm. Finally, under the action of ca. 1 equivalent of EtONa pentafluorobenzene became the only polyfluoroaromatic product.

$$C_{6}F_{5}SiF_{3} + \langle 1[EtO]^{-}$$

$$\longrightarrow C_{6}F_{5}SiF_{2}OEt + [C_{6}F_{5}SiF_{3}(OEt)]^{-}$$

$$+ C_{6}F_{5}H \qquad (10)$$

$$C_{6}F_{5}SiF_{3} + 1[EtO]^{-} \longrightarrow C_{6}F_{5}H + SiF_{n}(OEt)_{4-n}$$

The interaction of trifluorosilane 5 with piperidine (2 equivalents) in hexane led to formation of pentafluorobenzene and pentafluorophenylpiperidinodifluorosilane (1:1 mol). Further treatment of the reaction mixture with piperidine (2 equivalents) resulted in pentafluorophenylbis(piperidino)fluorosilane and C_6F_5H (1:2

mol). In excess of that amine pentafluorobenzene was the only polyfluoroaromatic product.

$$C_{6}F_{5}SiF_{3} \xrightarrow{2 R_{2}NH} C_{6}F_{5}H + SiF_{3}NR_{2}$$

$$\xrightarrow{2 R_{2}NH} C_{6}F_{5}H + SiF_{3}NR_{2}$$
(12)

$$C_{6}F_{5}SiF(NR_{2})_{2} + C_{6}F_{5}H + SiF_{2}(NR_{2})_{2}$$

$$\xrightarrow{>2 R_{2}NH} C_{6}F_{5}H + SiF_{n}(NR_{2})_{4-n}$$
(13)

In contrast to the interaction with EtONa, the generation of arylaminofluorosilicates was not observed here. One of the possible reasons is their fast reaction with acidic protons of the $[R_2NH_2]^+$ cation to give C_6F_5H .

Addition of BuLi (3 equivalents) to $C_6F_5SiF_3$ in hexane gave a mixture of $C_6F_5SiFBu_2$ and $C_6F_5SiBu_3$ (2:1 mol). Further alkylation with BuLi led to the formation of $C_6F_5SiBu_3$ and $4\text{-Bu}C_6F_4SiBu_3$. When $C_6F_5SiF_3$ was alkylated with 4.3 equivalents of BuLi in a mixture of hexane-diglyme, 4-butyltetrafluorophenyltributylsilane was the only polyfluoroaromatic reaction product. In both cases no pentafluorobenzene was detected. It should be mentioned that alkylation of $C_6F_5SiMe_3$ with BuLi in hexane led to formation of $4\text{-Bu}C_6F_4SiMe_3$ [5].

$$C_6F_5SiF_3 \xrightarrow{3 \text{ BuLi}} C_6F_5SiFBu_2 + C_6F_5SiBu_3$$
$$\xrightarrow{\text{BuLi}} C_6F_5SiBu_3 + 4 - BuC_6F_4SiBu_3 \quad (14)$$

These data point out the attack of nucleophiles at the silicon atom in C₆F₅SiF₃ independently from the "hardness" of the nucleophiles. However, the "hard"

Table 3 The 1 H and 29 Si NMR spectra of pentafluorophenylsilanes C_6F_5 SiXYZ (CDCl₃, 35 °C)

X	Y	Z	$\delta(^{29}Si)/ppm$	$J(^{29}Si^{-19}F)/Hz$	$\delta(^{1}H)/ppm$	$J(^{1}\mathrm{H}-^{1}\mathrm{H})/\mathrm{Hz}$
F	F	F a	- 77.78	248.0 (Si-F)		
				6.1 (Si-C-C-F)		
				6.1 (Si-C-C-C-F)		
Cl	Cl	Cl	-12.10	6.9 (Si-C-C-F)		
Cl	Cl	OEt	-33.91		1.46 (CH ₃)	7
					4.24 (OCH ₂)	7
OEt	OEt	OEt	-67.27	3.7 (Si-C-C-F)	1.30 (CH ₃)	7
				3.7 (Si-C-C-C-F)	3.95 (OCH ₂)	7
C_6F_5	F	F a	-39.85	281.5 (Si-F)	•	
C_6F_5	Cl	Cl	-8.23			
C_6F_5	OE t	OEt			1.35 (CH ₃)	6
0 3					4.10 (OCH ₂)	
Bu	Bu	Bu	-3.78		1.32, 0.86	
Bu	Bu	F	19.64	293.0 (Si-F)	1.39, 1.04, 0.88	
Bu	Bu	OEt	4.95		1.33, 0.95, 0.87 (C₄H₀),	
					3.74 (OCH ₂), 1.19 (CH ₃)	7

(11)

a in CD₂Cl₂.

oxygen- and nitrogen-containing nucleophiles seem to form arylfluorosilicates intermediately which lose $[C_6F_5^-]$ irreversibly under formation of C_6F_5H . In the case of piperidine pentafluorobenzene can be formed alternatively by protodesilylation of the intermediate silicate with the acidic $[R_2NH_2]^+$ cation. The absence of C_6F_5H in the alkylation of $C_6F_5SiF_3$ with BuLi indicates the predominant elimination of F^- from $[C_6F_5SiF_3Bu]^-$ rather than $[C_6F_5^-]$; also no protodesilylation of the intermediate silicate takes place.

A general scheme for the interaction of 5 with nucleophiles Nu⁻ is shown in Eq. (15).

$$C_{6}F_{5}SiF_{3} + Nu^{-} \iff [C_{6}F_{5}SiF_{3}(Nu)]^{-}$$

$$\iff C_{6}F_{5}SiF_{2}(Nu) + F^{-}$$

$$[C_{6}F_{5}SiF_{3}(Nu)]^{-} \iff [C_{6}F_{5}^{-}] + SiF_{3}(Nu)$$

$$\xrightarrow{H-B} C_{6}F_{5}H + B^{-} + SiF_{3}(Nu)$$

$$(15)$$

$$[C_6F_5SiF_3(Nu)]^- + H-B$$

$$\longrightarrow C_6F_5H + B^- + SiF_3(Nu)$$

Desilylation of $C_6F_5SiF_3$ with electrophiles in neutral or acidic media should proceed via addition of the electron-deficient species to the C-1 carbon atom. However, the substituent $[F_3Si^+]$ is a very poor leaving group and therefore its successful displacement requires nucleophilic assistance.

This proposal rationalises the observed inertness of trifluorosilane 5 to strong anhydrous acids and $[NO_2]^+$ $[BF_4]^-$ (weak nucleofuge counteranions $[H_nF_{n+1}]^-$, $[FSO_3]^-$, $[BF_4]^-$), whereas electrophilic bromine in the adduct Br_2 –AlBr₃ was more reactive due to the transfer of bromide from $[AlBr_4]^-$ to silicon. In liquid bromine a second molecule of pentafluorophenyltrifluorosilane can principally assist as Lewis acid instead of AlBr₃ to give C_6F_5 Br and C_6F_5 SiF₂Br. Hence every desilylation of C_6F_5 SiF₃ by electrophiles should include the participation of whether a nucleophilic counteranion or the solvent when the reaction is carried out in basic media.

3. Experimental section

The ¹H and ¹⁹F NMR spectra were recorded on a Varian EM 360 L (¹H at 60.0 MHz and ¹⁹F at 56.4

MHz), a Bruker WP 80 SY ($^{19}\,F$ at 75.4 MHz), WP 200 SY ($^{1}\,H$ at 200.0 MHz, $^{19}\,F$ at 188.3 MHz) and AM 400 ($^{13}\,C$ at 100.6 MHz, $^{29}\,Si$ at 79.5 MHz) spectrometer (TMS and $C_6\,F_6$ as internal references). The $^{19}\,F$ chemical shifts were assigned to CFCl $_3$ using $\delta(F)=-162.9$ ppm for $C_6\,F_6$. The IR spectra were registered on a Specord M 80, a Perkin Elmer 557 and a Nicolet 20 DXB instrument and the Raman spectra on a Ramalog 5 M spectrometer (Kr laser, red line at 15453.5 cm $^{-1}$).

The compounds SbF₅, IF₅, SO₂FCl, SOCl₂, HSO₃F and piperidine were distilled before use. EtONa was prepared from sodium and anhydrous EtOH and kept at 140–150 °C in high vacuum for 4 h. [NO₂]⁺ [BF₄]⁻ (Fluka) was used without further purification. Pentafluorophenyltriethoxysilane (1), bis(pentafluorophenyl)diethoxysilane (3) [11] and [IF₄]⁺ [SbF₆]⁻ [26] were synthesised by known methods. All manipulations with pentafluorophenylfluorosilanes were carried out in FEP tube reactors.

3.1. Pentafluorophenyltriethoxysilane (1)

IR (neat liquid): 2981, 2932, 1644, 1519, 1468, 1386, 1292, 1169, 1116, 1092, 973, 792, 688, 636, 620, 522, 469 cm⁻¹. Raman: 2985 (29.5), 2935 (37.7), 2900 (19.3), 1645 (18.7), 1480 (15.5), 1470 (25.3), 1447 (23.8), 1385 (10.4), 1300 (18.0), 1143 (9.8), 1100 (19.8), 1093 (19.3), 975 (10.4), 942 (9.2), 846 (23.6), 800 (15.1), 687 (11.4), 627 (7.9), 587 (55.2), 520 (21.4), 472 (12.8), 448 (95.7), 400 (100), 352 (20.4), 287 (12.2), 238 (16.1), 205 (16.7) cm⁻¹.

3.2. Pentafluorophenyltrichlorosilane (2)

Pentafluorophenyltriethoxysilane 1 (35.7 g, 0.108 mol), thionylchloride (48 ml, 0.658 mol) and pyridinium hydrochloride (1.6 g, 0.014 mol) were refluxed and stirred for 24 h. Excess of SOCl₂ was distilled off and pentafluorophenyltrichlorosilane isolated by vacuum-distillation. Yield 27.2 g (83%), bp 45 °C (1.5 Torr) (lit. 64–65 °C (5 Torr) [14,15], 80–84 °C (14 Torr) [11]). Raman: 1650 (9.0), 1393 (4.0), 1148 (2.2), 859 (5.4), 593 (76.0), 546 (2.6), 480 (90.3), 450 (93.7), 398 (89.9), 363 (13.2), 310 (12.0), 281 (3.7), 236 (9.7), 218 (13.7), 204 (9.8), 173 (100.0), 148 (96.8) cm⁻¹.

3.3. Bis(pentafluorophenyl)dichlorosilane (4)

4 was obtained in a similar way as $(C_6F_5)_2Si(OEt)_2$ (4.94 g, 10.9 mmol), $SOCl_2$ (3.3 ml, 45 mmol) and pyridinium hydrochloride (0.15 g, 1.3 mmol). Yield 3.05 g (64 %), bp 100–103 °C (1.5 Torr) (lit. 180–182 °C (16 Torr) [11]). The intermediate formation of $(C_6F_5)_2SiClOEt$ was detected by ¹⁹ F NMR spectrometry (not isolated).

3.4. Pentafluorophenyldichloro(ethoxy)silane

Pentafluorophenyltriethoxysilane 1 (39 g, 0.118 mol), thionyl chloride (55 ml, 0.76 mol) and pyridinium hydrochloride (1.5 g, 1.4 mmol) were refluxed and stirred for 4 h. Silane $C_6F_5SiCl_2OEt$ (18 g, 49%) was isolated by vacuum-distillation, bp 96–99 °C (4 Torr). Found: C 30.6, H 1.91, Cl 23.0, F 30.4. $C_8H_5Cl_2F_5OSi$. Required: C 30.9, H 1.61, Cl 22.8, F 30.5. IR (neat liquid): 2985, 2941, 2908, 1644, 1530, 1473, 1460, 1386, 1298, 1168, 1100, 976, 780, 752, 730 cm⁻¹.

3.5. Fluoridation of $C_6F_5Si(OEt)_3$ with AHF

3.5.1. In neat AHF

A mixture of $C_6F_5Si(OEt)_3$ (170 mg, 0.51 mmol) and AHF (anhydrous HF, 0.25 ml) was shaken at -50 °C for 3 h. After 3 h the acidic phase was separated and the organic phase was diluted with dichloromethane (0.15 ml). The solution contained $C_6F_5SiF_3$ (8%) and C_6F_5H (22%). The acidic phase contained $C_6F_5SiF_3$ (26%) and C_6F_5H (41%). The total yields of $C_6F_5SiF_3$ and C_6F_5H were 34 and 63% respectively (¹⁹F NMR, quantitative reference $C_2F_3Cl_3$ (organic phase) and CF_3CO_2Na (acidic phase).

3.5.2. In $CH_{2}Cl_{2}$

AHF (0.3 ml) was added to a solution of $C_6F_5Si(OEt)_3$ (91.5 mg, 0.28 mmol) in dichloromethane (0.2 ml) at -50 °C and stirred for 4 h. The organic phase contained $C_6F_5SiF_3$ (48%) and C_6F_5H (9%). $C_6F_5SiF_3$ (26%) and C_6F_5H (18%) were found in the AHF phase. The total yields of $C_6F_5SiF_3$ and C_6F_5H were 74% and 26% respectively.

3.6. Pentafluorophenyltrifluorosilane (5)

Method A. Freshly sublimed antimony trifluoride (12.3 g, 68.8 mmol) was added in one portion to pentafluorophenyltrichlorosilane (2) (17.02 g, 56.5 mmol) into a round bottom flask equipped with reflux condenser. After a short inductive period the exothermic reaction started. The reaction mixture was refluxed for 1 h. Pentafluorophenyltrifluorosilane was distilled off at reduced pressure and re-distilled. Yield of $C_6F_5SiF_3$ 13.47 g (94%), bp 44 °C (64 Torr) (lit. 105 °C [12]).

Raman: 1653, 1403, 1154, 908, 630, 586, 518, 445, 410, 399, 345, 323, 280, 238, 219, 158 cm⁻¹.

Method B. AHF (0.35 ml) was added into a solution of trichlorosilane 2 (251 mg, 0.83 mmol) in dichloromethane (0.2 ml) at -50 °C and stirred for 3 h. When the evolution of HCl subsided, trifluorosilane 5 was found in the organic (91%) and AHF (11%) phase (quantitative yield).

3.7. Reaction of $C_6F_5Si(OEt)_3$ with EtOH in AHF

Triethoxysilane 1 (210 mg, 0.636 mmol) was dissolved in a solution of EtOH (0.074 ml, 1.27 mmol) in AHF (0.2 ml) at -40 °C. After 1 h the ratio C_6F_5H : $C_6F_5SiF_3$ was equal 35:1 (mol) and no $C_6F_5Si(OEt)_3$ was found.

3.8. Reaction of $C_6F_5SiF_3$ with EtOH in AHF

Ethanol (0.01 mmol) was added to $C_6F_5SiF_3$ (25 mg, 0.01 mmol) in AHF (0.3 ml) at -50 °C. No reaction was detected after shaking for 1 h (^{19}F NMR). Then an excess of EtOH (0.1 ml) was added and the reaction mixture was kept at -10 °C for 1 d and at -78 °C for 2 d. Pentafluorobenzene and pentafluorophenyltrifluorosilane were found in 86 and 14% yields (^{19}F NMR).

3.9. Bis(pentafluorophenyl)difluorosilane (6)

6 was obtained similarly to trifluorosilane 5 (method A) from $(C_6F_5)_2SiCl_2$ (7.65 g, 17 mmol) and SbF_3 (3.34 g, 18.7 mmol) at ca. 60 °C (bath). Yield of $(C_6F_5)_2SiF_2$ was 4.42 g (65%), bp 126 °C (60 Torr) (lit. 207 °C [10]).

3.10. Attempted reaction of triethoxysilane 1 with SOBr,

A mixture of $C_6F_5Si(OEt)_3$ (5.0 g, 15 mmol), freshly distilled $SOBr_2$ (8 ml, 103 mmol) and pyridine (1.2 g, 15 mmol) was stirred at 45–50 °C for 7 h. No reaction was detected (¹⁹F NMR).

3.11. Reaction of $C_6F_5Si(OEt)_3$ with BF_3 or $BF_3 \cdot OEt_2$

Method A. Triethoxysilane 1 (6.0 g, 18 mmol) and $BF_3 \cdot OEt_2$ (7.5 g, 53 mmol) were stirred for 30 h at room temperature. According to the ¹⁹F NMR spectrum, trifluorosilane 5 was the main product together with $C_6F_5SiF(OEt)_2$, $C_6F_5SiF_2OEt$ and $(EtOBF_2)_3$. The isolation of $C_6F_5SiF_3$ from the reaction mixture by distillation failed (azeotrope formation with boron ethoxyfluorides; bp 78–83 °C).

Method B. Triethoxysilane 1 (8.0 g, 24 mmol) and BF₃·OEt₂ (10.0 g, 70 mmol) were refluxed for 11 h. The composition of the reaction mixture was similar to that mentioned above.

Method C. Pentafluorophenyltriethoxysilane (12.48 g, 37.8 mmol) was added dropwise to $BF_3 \cdot OEt_2$ (4.8 ml, 38.2 mmol) at 108-110 °C during 5 min. After 30 min the volatile products were distilled off and the residue was distilled in vacuum to give $BF_3 \cdot OEt_2$, (EtOBF₂)₃ and (EtO)₂BF (identified by their ¹⁹F NMR) and a mixture of $C_6F_5SiF_3$, $C_6F_5SiF_2OEt$ and $C_6F_5SiF(OEt)_2$, bp 23–98 °C (24 Torr) (7.24 g, 1:7.4:2.7 mol) (not separated).

Method D. Boron trifluoride was bubbled through a solution of $C_6F_5Si(OEt)_3$ (1.0 g, 3 mmol) in CH_2Cl_2 (8 ml) at room temperature during 5 h. The excess of BF_3 was removed by a stream of argon and the solvent was distilled off. The residue (1.8 g) (bp 78–80 °C) contained $C_6F_5SiF_3$, $C_6F_5SiF_2OEt$ (1.6:1 mol) and $(EtOBF_2)_3$.

3.12. Reaction of $C_6F_5Si(OEt)_3$ with SF_4

A solution of triethoxysilane 1 (1.0 g, 3 mmol) in CH_2Cl_2 (10 ml) was treated with SF_4 (HF free) for 1.5 h at room temperature. Only traces of $C_6F_5SiF(OEt)_2$ were detected (¹⁹F NMR).

3.13. Attempted reactions of trifluorosilane 5 with acids

A solution of $C_6F_5SiF_3$ (0.5–0.6 mmol) in acid (AHF, HSO₃F or CF_3CO_2H) (0.15–0.5 mmol) was kept at room temperature for 3 days. No reaction was detected (^{19}F NMR).

3.14. Attempted reactions of $C_6F_5SiF_3$ with IF_5

A solution of C₆F₅SiF₃ and IF₅ (1:1 mol) in CH₂Cl₂ or HF (0.1–0.2 ml) was kept at room temperature for 24–36 h. No reactions were detected (¹⁹F NMR).

3.15. Interaction of $C_6F_5SiF_3$ with $[NO_2]^+$ $[BF_4]^-$

Method A. A suspension of $C_6F_5SiF_3$ and $[NO_2]^+$ $[BF_4]^-$ (1:1 mol) in dichloromethane was shaken at room temperature for 41 h. No reaction was detected (19 F NMR).

Method B. The same result was obtained for the clear colourless solution of $C_6F_5SiF_3$ (88 mg, 0.35 mmol) and $[NO_2]^+$ $[BF_4]^-$ (73 mg, 0.55 mmol) in 0.15 ml of HSO₃F after 41 h.

3.16. Reactions of $C_6F_5SiF_3$ with bromine

Method A. No reaction was detected between $C_6F_5SiF_3$ (44 mg, 0.17 mmol) and bromine (122 mg, 0.77 mmol) in acetonitrile (0.1 ml) at room temperature within 42 h.

Method B. C₆F₅SiF₃ (69 mg, 0.27 mmol) and bromine (588 mg, 3.67 mmol) were kept for 10 days at

room temperature to give a mixture of $C_6F_5SiF_3$, C_6F_5Br and $C_6F_5SiF_2Br$ (1:1:0.6 mol).

Method C. A mixture of bromine (1.24 mmol) and AlBr₃ (0.62 mmol) was cooled down to -20 °C and $C_6F_5SiF_3$ (120 mg, 0.47 mmol) was added. The reaction mixture was kept at room temperature for 48 h to give $C_6F_5SiF_3$, C_6F_5Br (1:4 mol) and bromofluorosilanes SiF_2Br_2 and $SiFBr_3$ (19 F resonances at -96.1 and -77.4 ppm (singlets) respectively [29]). After 76 h all $C_6F_5SiF_3$ was converted to C_6F_5Br .

3.17. Reaction of $C_6F_5SiF_3$ with $[IF_4]^+$ $[SbF_6]^-$

Trifluorosilane 5 (83 mg, 0.33 mmol) and $[IF_4]^+$ [SbF₆]⁻ (177 mg, 0.40 mmol) were dissolved in HSO₃F (0.2 ml) forming a green solution which displayed ¹⁹F resonances at 19.3 ($[IF_4]^+$), -125.2, -133.9, -143.4and -159.4 ppm ($C_6F_5SiF_3$) (4:2:3:1:2 mol) together with signals of SiF_4 (-163.0 ppm), $[SbF_6]^-$ (-109 ppm, very broad) and HSO₃F (42.3 ppm). After 2 d the solution became red-brownish. Resonances at 18.3, -117.7, -135.3 and -152.8 ppm (4:2:1:2 mol) and signals of SiF₄, HSO₃F and [SbF₆] were observed in the ¹⁹F NMR spectrum. No further changes took place during the next 4 days. Evolved SiF4 was identified as SiF₄ · 2 Py adduct. The reaction mixture was poured onto ice frozen with liquid nitrogen. The solid was separated by centrifugation and dried in high vacuum at room temperature (76 mg). Its IR spectrum (in AgCl) and ¹⁹F NMR spectrum [30] displayed the presence of the $[(C_6F_5)_2I]^+$ cation.

3.18. Reaction of $C_6F_5SiF_3$ with BuLi

Method A. Trifluorosilane 5 (252 mg, 1.00 mmol) in hexane (0.5 ml) was treated with 1 M BuLi in hexane (3 ml) at -20 °C and warmed up to room temperature. The $^{19}\mathrm{F}$ NMR spectrum showed the presence of $\mathrm{C_6F_5SiFBu_2}$ and $\mathrm{C_6F_5SiBu_3}$ (2:1 mol). Further treatment with BuLi (1 ml) led to the formation of $\mathrm{C_6F_5SiBu_3}$ and admixture of $4\text{-BuC}_6\mathrm{F_4SiBu_3}$.

Method B. The addition of 1.6 M BuLi in hexane (1.5 ml, 2.4 mmol) into a solution of $C_6F_5SiF_3$ (140 mg, 0.55 mmol) in diglyme (0.5 ml) at -25 °C and the following warming up to room temperature resulted in the complete conversion of trifluorosilane 5 into 4-Bu $C_6F_4SiBu_3$ (¹⁹F NMR).

3.19. Reaction of $C_6F_5SiF_3$ with piperidine

The solution of $C_6F_5SiF_3$ (68 mg, 0.27 mmol) in hexane (0.5 ml) was cooled down to -20 °C and a solution of piperidine in hexane (2 equivalents) was added in one portion by syringe. The resulting suspension was warmed up to room temperature and centrifugated. The ¹⁹F NMR spectrum showed the presence of

 $C_6F_5SiF_2(NR_2)$ and C_6F_5H (1:1 mol). Further treatment of this solution with piperidine (2 equivalents) caused the appearance of $C_6F_5SiF(NR_2)_2$ and C_6F_5H (1:2 mol). Treatment of this solution with piperidine (excess) gave pentafluorobenzene as the only polyfluoroaromatic product (quantitative yield).

3.20. Reaction of $C_6F_5SiF_3$ with sodium ethoxide

Solid EtONa (10 mg, 0.15 mmol) was added to a solution of $C_6F_5SiF_3$ (109 mg, 0.43 mmol) in 0.2 ml of diglyme at -30 °C. The reaction mixture was heated to room temperature with shaking. The ¹⁹F NMR spectrum displayed signals of C_6F_5H and resonances at -123.2 (Si-F, broad), -126.6 (F 2, 6), -147.6 (F-4) and -160.7 (F-3, 5) ppm (the molar ratio of C_6F_5H to silanes and silicate was 1 to 3). Further addition of EtONa (total amount 32 mg, 0.47 mmol) led to the formation of pentafluorobenzene only.

3.21. Pentafluorophenyldibutylethoxysilane

Pentafluorophenyltriethoxysilane (3.30 g, 10 mmol) was added dropwise to a solution of BuMgBr prepared from BuBr (4.00 g, 30 mmol) and magnesium (0.72 g, 30 mmol) in ether (13 ml). The reaction mixture was refluxed for 5 h and kept overnight at room temperature. After extraction with hexane (3 x 10 ml) and filtration the solvent was distilled off in vacuum to give 2.4 g (68%) of $C_6F_5SiBu_2OEt$, bp 125–128 °C (8 Torr).

Found: C 54.9, H 6.66, F 27.4. C₁₆H₂₃F₅OSi. Required: C 54.2, H 6.50, F 26.8. IR (neat liquid): 2958, 2927, 2870, 2854, 1636, 1511, 1455, 1405, 1368, 1280, 1192, 1158, 1104, 1075, 964, 877, 780, 765, 733, 693, 496 cm⁻¹.

3.22. Pentafluorophenyldibutylfluorosilane

 $C_6F_5SiBu_2OEt~(1.8~g,~5.0~mmol)$ was refluxed in acetylchloride (1.2 g, 15 mmol) with $ZnCl_2~(ca.~0.2~g)$ for 8 h. The liquid phase was decanted and the volatile products removed at $50-70~^{\circ}C~(bath)$. Crude $C_6F_5SiBu_2Cl$ was heated with $ZnF_2~(3.0~g,~29~mmol)$ at $200-220~^{\circ}C~(bath)$ for 30 min and $C_6F_5SiBu_2F$ was distilled off in vacuum. Yield 1.1 g (67 %), bp 142 °C (30 Torr).

Found: C 51.7, H 5.75, F 34.9. C₁₄H₁₈F₆Si. Required: C 51.2, H 5.49, F 34.8. IR (neat liquid): 2965, 2937, 2880, 2869, 1645, 1534, 1466, 1404, 1380, 1285, 1200, 1087, 970, 893, 855, 790, 700, 505 cm⁻¹.

3.23. Pentafluorophenyltributylsilane

A solution of BuLi in hexane (0.9 M, 26 ml, 23.4 mmol) was added dropwise to a stirred solution of

triethoxysilane 1 (2.20 g, 6.7 mmol) in hexane (2 ml) at -20 °C. The reaction mixture was stirred at room temperature for 2 h and poured into diluted HCl. The organic layer was washed with water, dried with CaCl₂ and the solvent removed. Distillation of the residual oil in vacuum gave $C_6F_5SiBu_3$ (1.25 g, 51%), bp 148–151 °C (5 Torr).

Found: C 58.5, H 7.00, F 26.1. C₁₈H₂₇F₅Si. Required: C 59.0, H 7.38, F 26.0.

3.24. 4-Butyltetrafluorophenyltributylsilane

A solution of triethoxysilane 1 (1.10 g, 3.3 mmol) in hexane (2 ml) was transferred by syringe into a solution of 0.9 M BuLi in hexane (22.5 mmol) at 0 °C. Then the reaction mixture was treated as mentioned above to yield 4-BuC $_6$ F $_4$ SiBu $_3$ (0.62 g, 46%), bp 185–188 °C (5 Torr).

Found: C 65.0, H 8.71, F 19.0. C₂₂H₃₆F₄Si. Required: C 65.3, H 8.91, F 18.8.

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